IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Won Kwon Lee) I hereby certify that this Patent
Serial No.: To be assigned	Application Transmittal and the documents referred to as enclosed therewith are being deposited with the
Filed: July 18, 2003 (herewith)	United States Postal Service onJuly 18, 2003, in an envelope addressed
For: Method of Forming Isolation Films in Semiconductor Devices) to the Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313- 1450 utilizing the "Express Mail Post Office to Addressee" service of the United
Group Art Unit: To be assigned	States Postal Service under Mailing LabelNo. EV323773409US.
Examiner: To be assigned	Richard Zipmermann

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

Submitted herewith for consideration by the examiner are copies of the documents identified on the attached PTO SB/08. Entry and consideration of the submitted documents is solicited.

The Commissioner is authorized to charge any fee deficiency required by this paper, or credit any overpayment, to Deposit Account No. 13-2855.

Respectfully submitted,

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July 18, 2003

By:

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Substitute for form 1449A/PTO		Complete if Known			
				Application Number	To be assigned
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l s	STATEMENT BY APPLICANT			First Named Inventor	Won Kwon Lee
(use as many sheets as necessary)				Art Unit	To be assigned
			necessary)	Examiner Name	To be assigned
Sheet	1	of	1	Attorney Docket Number	29936/39477

U.S. PATENT DOCUMENTS					
Examiner Cite Initials* No.1	0.1	Document Number	Publication Date	Name of Potentee or Applicant	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code ² (if known)	1	Name of Patentee or Applicant of Cited Document	
		6,413,828	07-02-2002	Lam	
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	FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No.1	Foreign Patent Document Country Code ³ -Number A-Kind Code ⁵ (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ⁶	
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¹ Applicant's unique citation designation number (optional). ² See attached Kinds Codes of USPTO Patent Documents at www.uspto.gov or MPEP 901.04. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the application number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to place a check mark here if English language Translation is attached.

OTHER PRIOR ART – NON PATENT LITERATURE DOCUMENTS					
Examiner Initials	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²		
		Li, C.H. et al. "A robust shallow trench isolation (STI) with SiN pull-back process for advanced DRAM technology," <i>Advanced Semiconductor Manufacturing</i> 2002, <i>IEEE/SEMI Confrence and Workshop</i> 2002 pp. 21-26.	1		

Examiner		Date	
Signature	·	Considered	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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